



APPLICATION DATA SHEET

Electronic Version v14

Stylesheet Version v14.0

Title of Invention	TWO-SIDED CHEMICAL MECHANICAL POLISHING PAD FOR SEMICONDUCTOR PROCESSING		
Application Type : regular, utility Attorney Docket Number : FIS920030277			
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Publication Information:

Suggested Figure for Publication - 4C

Suggested Classification -

Suggested Technology Center -

Total Number of Drawing Sheets - 5

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